

AISthesis Products

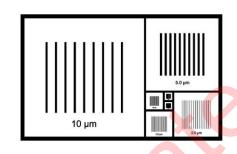
Advanced Imaging Products for Nanotechnology, **Engineering and Life Sciences** PO Box 1950, Clyde NC 28721





Wafer Level Certificate of Traceability for Pelcotec™ Critical Dimension Magnification Standard





Product Number: Pelcotec™ 708-01 CDMS-0.1T-ISO-Etched Customer name and contact information:

Product Description: 2.5x2.5mm, **Pelcotec™** 2mm-100nm

Critical Dimension Magnification Standard

Wafer Identifier: CD-BH05

As Received Condition: New

As Returned Condition: N/A

Date of Receipt: N/A

'ED PELLA

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The accuracy of this product with Wafer Identifier CD-BH05 was determined using a Field Emission Scanning Electron Microscope (FE-SEM) by reference comparison to working standards traceable to the National Institute of Standards and Technology (NIST), using CP 01 FE-SEM Imaging of Critical Dimension Magnification Standards (CDMS) and CP 02 Certification of Critical Dimension Magnification Standards. Die were sampled according to method SOP 07 Sampling Die. The data applies only to the CDMS products identified in this report. All results are "as-is". Repair and/or adjustments are not possible.

Below are the average ISO 17025:2017 Accredited Average 10 µm Pitch Measurements unique to Die with Wafer Identifier CD-BH05 and traceable to NIST Certified Standard CD-PG01-0211.

Line	ISO 17025:2017 Accredited Average Pitch on Wafer	Position of Measurement
0-10 µm	9.998 µm	± 7.5 µm from center
1 <mark>0</mark> -20 μm	10.000 μm	± 7.5 µm from center
20-30 μm	10.003 μm	± 7.5 µm from center
30-40 μm	10.000 μm	± 7.5 µm from center
40-50 µm	10.002 μm	± 7.5 µm from center
50-60 µm	9.999 µm	± 7.5 µm from center
60-70 μm	10.000 μm	± 7.5 µm from center
70-80 μm	9.998 µm	± 7.5 µm from center

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Sum	80.000 μm
Average	10.000 μm
2-Sigma *	0.0042 um

* Corrected for sample size using the appropriate Student t-factor.

Measurements are reported with an uncertainty $(k=2)^{**}$ of \pm 0.012 μ m. Statements of Conformity are not provided in this report. Review the results and verify that they meet the requirements for the intended use. Physical damage to or contamination of the CDMS occurring after calibration may invalidate the reported measurements. Use this product at 25°C \pm 5°C and at less than 80% RH.

Below are the Non-ISO 17025:2017 Accredited Average Pitch Measurements unique to Die with Wafer Identifier CD-BH05 and traceable to NIST Certified Standard CD-PG01-0211.

Line	Number of Lines	Position of Measurement	Non-ISO 17025:2017 Accredited Average Measured Distance (first to last line)	Average Pitch of Wafer
2.0 mm	2	± 1.00mm from center	2.000 mm	2.000 mm
1.0 mm	2	± 0.5mm from center	1.000 mm	1.000 mm
0.5 mm	2	± 0.25mm from center	0.500 mm	0.500 mm
0.25 mm	2	± 0.125mm from center	0.250 mm	0.250 mm
5.0 µm	12	± 20 µm from center	55.015 µm	5.00 µm
2.0 µm	16	± 10 µm from center	30.041 µm	2.00 μm
1.0 µm	17	± 5 µm from center	16.024 μm	1.00 μm
500 nm	20	± 4 µm from center	9.519 µm	501.0 nm
250 nm	21	± 2.5 µm from center	5.016 µm	250.8 nm
100 nm	52	± 2.5 µm from center	5.115 µm	100.3 nm

The average pitch is derived from the stated length that was determined using measurements (taken center-to-center) over the stated number of lines (i.e., length divided by the number of lines minus one).

Date of Analysis: December 2nd, 2024

Equipment used:

Instrument	Model	Serial #	Resolution	Repeatability	Temperature	Humidity	Reference
FE-SEM	FEI Apreo2	9958357	0.9nm	0.030%	21.9 ± 0.1 °C	33.3 ± 0.8%	CD-PG01-0211

Location: AISthesis Products, Inc., PO Box 1950, Clyde North Carolina 28721.

Notes:

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^{**} Reported uncertainties represent expanded uncertainties expressed at approximately the 95% confidence level using a coverage factor of k = 2. The reported expanded measurement uncertainty is stated as the standard measurement uncertainty multiplied by the coverage factor K such that the coverage probability corresponds to approximately 95%.

D.S. Finch		
Certified by	Signature	
H. Haehlen		December 2 nd , 2024
Authorized by	Signature	Date report issued.

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End of report.

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